

Amendment to the Claims

Please withdraw claims 7, 12 and 13 without prejudice to having these claims reconsidered upon allowance of a generic claim.

C' 1. (Original) An apparatus for detecting characteristics of a microelectronic substrate having a first surface with first topographical features and a second surface facing opposite from the first surface and having second topographical features, the apparatus comprising:

a support member configured to carry the microelectronic substrate with a first portion of the first surface exposed and a second portion of the second surface exposed; and

a topographical feature detector positioned proximate to the support member and aligned with the first portion of the first surface of the microelectronic substrate, the topographical feature detector including a non-capacitive detection device configured to detect roughness characteristics of the first surface when the microelectronic substrate is carried by the support member.

2. (Original) The apparatus of claim 1 wherein the topographical feature detector is configured to:

determine distances from a reference plane to a plurality of the first topographical features;

select from the determined distances a minimum distance value;

select from the determined distances a maximum distance value; and

subtract the minimum distance value from the maximum distance value.

3. (Original) The apparatus of claim 1 wherein the second topographical features include conductive structures protruding from the second surface, and wherein the topographical feature detector is a first topographical feature detector, and wherein the apparatus further comprises a second topographical feature detector positioned

proximate to the support member and configured to detect a characteristic of the second topographical features when the microelectronic substrate is supported by the support member.

4. (Original) The apparatus of claim 1 wherein at least one of the topographical feature detector and the support member is movable relative to the other while the microelectronic substrate is carried by the support member.

C1
(cont'd)

5. (Original) The apparatus of claim 1 wherein the topographical feature detector includes of a first system configured to detect roughness features of microelectronic substrates having a first range of thicknesses, the first system being interchangeable with a second system configured to detect roughness features of microelectronic substrates having a second range of thicknesses, with a maximum thickness of the second range being greater than a maximum thickness of the first range.

6. (Original) The apparatus of claim 1 wherein the second topographical feature includes a solder bump, and wherein the apparatus further comprises a raised feature detector positioned proximate to the support member and configured to detect a characteristic of the solder bump.

7. (Withdrawn)

8. (Original) The apparatus of claim 1, further comprising:

C2

a first camera positioned proximate to the support member and configured to detect at least one of a position, a surface defect and a bridge of at least one of the second topographical features of the microelectronic substrate when the microelectronic substrate is supported by the support member; and

a second camera positioned proximate to the support member and configured to detect a height of at least one of the second topographical features of the

microelectronic substrate when the microelectronic substrate is supported by the support member.

9. (Original) The apparatus of claim 1 wherein the support member has a contact surface with a plurality of apertures, the apertures being coupleable to a vacuum source to draw the microelectronic substrate into contact with the support member.

10. (Original) The apparatus of claim 1 wherein the support member has a generally ring-shaped contact surface, and wherein the first portion of the first surface of the microelectronic substrate is disposed annularly inwardly from the contact surface when the support member carries the microelectronic substrate.

11. (Original) The apparatus of claim 1 wherein the topographical feature detector includes a probe having a contact portion configured to contact the microelectronic substrate, the topographical feature detector being configured to detect a roughness of the microelectronic substrate based on measurements at a plurality of locations on the microelectronic substrate.

12. (Withdrawn)

13. (Withdrawn)

14-97. (Canceled)